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APPLICATION N	10.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/762,849		01/22/2004	Matthew Prince	ITL.0941US (P15694)	5852
21906	7590	08/15/2005		EXAM	INER
TROP P	RUNER &	& HU, PC	SHAKERI, HADI		
8554 KA	TY FREE	WAY			
SUITE 10	00		ART UNIT	PAPER NUMBER	
HOUSTO	HOUSTON, TX 77024			3723	
				DATE MAIL ED: 08/15/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s) PRINCE ET AL.	
	10/762,849		
Office Action Summary	Examiner	Art Unit	
	Hadi Shakeri	3723	
The MAILING DATE of this communication Period for Reply	appears on the cover sheet w	vith the correspondence address	
A SHORTENED STATUTORY PERIOD FOR RI THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CF after SIX (6) MONTHS from the mailing date of this communication - If the period for reply specified above is less than thirty (30) days, - If NO period for reply is specified above, the maximum statutory period for reply within the set or extended period for reply will, by some any reply received by the Office later than three months after the rearned patent term adjustment. See 37 CFR 1.704(b).	ON. FR 1.136(a). In no event, however, may a n. a reply within the statutory minimum of thin eriod will apply and will expire SIX (6) MON statute, cause the application to become A	reply be timely filed rty (30) days will be considered timely. NTHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).	
Status			
1) Responsive to communication(s) filed on _			
	This action is non-final.		
3) Since this application is in condition for all	owance except for formal mat	ters, prosecution as to the merits is	
closed in accordance with the practice und	ler <i>Ex parte Quayle</i> , 1935 C.D	D. 11, 453 O.G. 213.	
Disposition of Claims			
4)⊠ Claim(s) <u>1-20</u> is/are pending in the applica	tion		
4a) Of the above claim(s) is/are with			
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>1-20</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction are	nd/or election requirement.		
pplication Papers			
9)⊠ The specification is objected to by the Exar	niner.		
10)⊠ The drawing(s) filed on 22 January 2004 is		bjected to by the Examiner.	
Applicant may not request that any objection to		· ·	
Replacement drawing sheet(s) including the co.			
11) The oath or declaration is objected to by the	e Examiner. Note the attached	d Office Action or form PTO-152.	
riority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for fore a) All b) Some * c) None of:	eign priority under 35 U.S.C. §	119(a)-(d) or (f).	
1. Certified copies of the priority docum	ents have been received.		
2. Certified copies of the priority docum			
3. Copies of the certified copies of the	oriority documents have been	received in this National Stage	
application from the International Bu	· ·		
* See the attached detailed Office action for a	list of the certified copies not	received.	
ttachment(s)			
) ☑ Notice of References Cited (PTO-892)) ☑ Notice of Draftsperson's Patent Drawing Review (PTO-948)		Summary (PTO-413) s)/Mail Date	

U.S. Patent and Trademark Office PTOL-326 (Rev. 1-04)

3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date

6) Other: _

5) Notice of Informal Patent Application (PTO-152)

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DETAILED ACTION

Drawings

1. Figure 1 should be designated by a legend such as --Prior Art-- because only that which is old is illustrated. See MPEP § 608.02(g). Corrected drawings in compliance with 37 CFR 1.121(d) are required in reply to the Office action to avoid abandonment of the application. The replacement sheet(s) should be labeled "Replacement Sheet" in the page header (as per 37 CFR 1.84(c)) so as not to obstruct any portion of the drawing figures. If the changes are not accepted by the examiner, the applicant will be notified and informed of any required corrective action in the next Office action. The objection to the drawings will not be held in abeyance.

Specification

2. The disclosure is objected to because of the following informalities: page 2, line 2, describes the figure as an embodiment of the present invention, whereas it only discloses a wafer covered by dielectric layers (14, 16), barrier layer (18) and copper layer (20) filling the trench (22); all known in the art as admitted by the Applicant on page 1.

Appropriate correction is required.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 4. Claims 16, 17, 19 and 20 are rejected under 35 U.S.C. 102(b) as being clearly anticipated by Tredinnick et al. (3,715,842).

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Tredinnick et al. discloses all of the limitations of claim 16, i.e., aging a silica slurry for at least fifty days (12 weeks) from its manufacture date and using to CMP a layer, wherein the layer is non-metallic, i.e., silicon wafer.

Claim Rejections - 35 USC § 103

- **5.** The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 6. Claims 11, 12 and 18 are rejected under 35 U.S.C. 102(b) as anticipated by Tredinnick et al. or, in the alternative, under 35 U.S.C. 103(a) as obvious over Tredinnick et al. in view of Applicant's Admitted Prior Art (AAPA).

Tredinnick et al. as described above discloses all of the limitations of claim 11, i.e., aging a silica slurry for at least fifty days (12 weeks) from its manufacture date and using to CMP a metallic layer, i.e., metalloid germanium, however in the alternative, it is known in the art to use silica slurry in the CMP step of damascene process in manufacturing semiconductor integrated circuits as admitted by Applicant on page 1. It would have been obvious to one of ordinary skill in the art, at the time the invention was made, to use the silica slurry with the thickening agent as disclosed by Tredinnick et al., in the damascene process to define a copper line in a trench, as this process is known in the art, in prevention of scratching the workpiece.

7. Claims 1-10 and 13-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tredinnick et al. in view of AAPA.

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Tredinnick et al. meets all of the limitations of claims 1 and 6, as explained above, except for using it on a tantalum containing layer. As indicated in section 6, it would have been obvious for one of ordinary skill in the art to use the slurry of Tredinnick et al. in a damascene process, which meets the limitations as recited.

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Conclusion

8. Prior art made of record and not relied upon are considered pertinent to applicant's disclosure. Avanzino et al., Roth, Kim et al., and Shimamoto et al. are cited to show related inventions.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hadi Shakeri whose telephone number is (571) 272-4495. The examiner can normally be reached on Monday-Thursday.

The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Hadi Shakeri Primary Examiner

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August 11, 2005